



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application

Inventor(s) Isik C. Kizilyalli  
Joseph R. Radosevich  
Pradip Kumar Roy

Case **46-19-123**

Serial No. **09/516004** Group Art Unit **2811**

Filing Date **February 29, 2000**

Examiner **O. Nadav**

Title **Selective Laser Anneal On Semiconductor Material**

**ASSISTANT COMMISSIONER FOR PATENTS**  
**WASHINGTON, D. C. 20231**

SIR:

**ELECTION OF CLAIMS**

In response to the Official Action of March 7, 2001, Applicant hereby elects to prosecute Group I, Claims 6-11, with traverse. It is submitted that the inventions of Groups I and II are not distinct because the process of Group II does not require providing dopant to spaced apart regions after forming a FET gate structure. Process claims are not limited to the sequence of recitation unless expressly stated in the claims. Withdrawal of the restriction requirement is required.

Respectfully Submitted,

Ferdinand M. Romano  
Reg. No. 32752  
Attorney for Applicants

Dated: 4/6/01

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks Washington, D.C. 20231 on 4-9-01

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Signature of person signing paper or file